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(54) Title: MICROCHIP DRUG DELIVERY DEVICES

(57) Abstract

Microchips are provided, which control both the rate and time of release of multiple chemical substances and which allow for th release of a wide variety of molecules in either a continuous or pulsatile manner. In all of the preferred embodiments, a material that i impermeable to the drugs or other molecules to be delivered and the surrounding fluids is used as the substrate. Reserv irs are etche into the substrate using either chemical (wet) etching or ion beam (dry) etching techniques well-known in the field of microfabricatior Hundreds to thousands of reservoirs can be fabricated on a single microchip using these techniques. A release system, which includes th molecules to be delivered, is inserted into the reservoirs by injection, inkjet printing or spin coating methods. Exemplary release system include polymers and polymeric matrices, non-polymeric matrices, and other excipients or diluents. The physical properties of the relea system control the rate of release of the molecules. The reservoirs can contain multiple drugs or other molecules in variable dosages. Tl filled reservoirs can be capped with materials that either degrade, dissolve, or allow the molecules to diffuse passively out of the reservc over time or materials that, upon application of an electric potential, oxidize to form soluble compounds or ions that dissolve into tl surrounding fluids. Release from an active device can be controlled by a preprogrammed microprocessor, remote control, or by biosensoi

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MICROCHIP DRUG DELIVERY DEVICES

Background of the Invention

This invention relates to miniaturized drug delivery devices and more particularly, to controlled time and rate release multi-welled drug

5   delivery devices.

Drug delivery is an important aspect of medical treatment. The efficacy of many drugs is directly related to the way in which they are administered. Some therapies require that the drug be repeatedly administered to the patient over a long period of time. This makes the

10   selection of a proper drug delivery method problematic. Patients often forget, are unwilling, or are unable to take their medication. Drug delivery also becomes problematic when the drugs are too potent for systemic delivery. Therefore, attempts have been made to design and fabricate a delivery device which is capable of the controlled, pulsatile or

15   continuous release of a wide variety of molecules including, but not limited to, drugs and other therapeutics.

Controlled release polymeric devices have been designed to provide drug release over a period of time via diffusion of the drug out of the polymer and/or degradation of the polymer over the desired time

20   period following administration to the patient. However, these devices are relatively simple.

U.S. Patent No. 5,490,962 to Cima, et al. discloses the use of three dimensional printing methods to make more complex devices which provide release over a desired time frame, of one or more drugs.

25   Although the general procedure for making a complex device is described, specific designs are not detailed.

U.S. Patent No. 4,003,379 to Ellinwood describes an implantable electromechanically driven device that includes a flexible retractable walled container, which receives medication from a storage area via an

30   inlet and then dispenses the medication into the body via an outlet. U.S. Patent No. 4,146,029 and U.S. Patent No. 3,692,027 to Ellinwood

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disclose self-powered medication systems that have programmable
miniaturized dispensing means. U.S. Patent No. 4,360,019 to Jassawalla
discloses an implantable infusion device that includes an actuating means
for delivery of the drug through a catheter. The actuating means includes
5   a solenoid driven miniature pump. All of these devices include miniature
power-driven mechanical parts that are required to operate in the body,
i.e., they must retract, dispense, or pump. These are complicated and
subject to breakdown. Moreover, due to complexity and size restrictions,
they are unsuitable to deliver more than a few drugs or drug mixtures at a
10   time.

        It is therefore an object of the present invention to provide a
simple to use and manufacture, dependable, multi-welled delivery device
for drugs and other molecules which can operate for weeks or years at a
time.

15   It is another object of the present invention to provide such a
device that allows delivery of drugs or other molecules in either a
pulsatile or continuous manner.

        It is yet another object of the present invention to provide such a
device that allows the delivery to be controlled either passively or
20   actively.

        It is also an object of the present invention to provide such a
device that can hold many different drugs or other molecules of varying
dosages and is small enough to be implanted, injected or swallowed, if
desired.

25   Summary of the Invention
        Microchips for delivery of a wide variety of molecules are
provided. Microchips are miniaturized devices constructed using methods
commonly applied to the manufacture of integrated circuits such as
ultraviolet (UV) photolithography, reactive ion etching, and electron beam
30   evaporation. The microchips provide control over the rate the molecules

are released as well as the time at which release begins. The time of release can be controlled passively or actively.

In the preferred embodiments, a material which is impermeable to the surrounding fluids and to the molecules to be delivered is used as the substrate. Examples of substrate materials include ceramics, semiconductors such as silicon, and degradable and non-degradable polymers. Reservoirs are etched into the substrate using either chemical (wet) etching or ion (dry) etching techniques commonly used in microfabrication. Hundreds to thousands of reservoirs can be created in this manner and contained in a single microchip. Typically, a release system containing, encapsulating, or consisting of the molecule to be delivered is inserted into the reservoirs by injection, inkjet printing, or other means. The release system controls the rate of release of the molecule. The rate of release is a function of the composition and structure of the release system. The device design makes it possible to fill the reservoirs with a release system in solid, liquid, or gel form. Each of the reservoirs of a single microchip can contain different molecules and/or different amounts and concentrations, which can be released independently.

In a preferred embodiment, the reservoir cap enables passive timed release, not requiring a power source, of molecules. The reservoirs are capped with materials that degrade or dissolve at a known rate or have a known permeability (diffusion constant) for the molecules to be delivered. Therefore, the degradation, dissolution or diffusion characteristics of the cap material determine the time at which the release of molecules in a particular reservoir begins. In effect, the microchip provides dual control of the release of molecules by selection of the release system (rate controller) and selection of the cap material (time controller, and in some cases, rate controller).

In another preferred embodiment, the reservoir cap enables active timed release, requiring a power source, of molecules. In this embodiment, the reservoir caps consist of a thin film of conductive

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material that is deposited over the reservoir, patterned to a desired geometry, and serves as an anode. Cathodes are also fabricated on the device with their size and placement dependent on the device's application and method of electric potential control. Conductive materials capable of

5   dissolving into solution or forming soluble compounds or ions upon the application of an electric potential, including metals such as copper, gold, silver, and zinc and some polymers, are used in the active timed release device. When an electric potential is applied between an anode and cathode, the conductive material of the anode above the reservoir oxidizes

10   to form soluble compounds or ions that dissolve into solution, exposing the release system containing the molecules to be delivered to the surrounding fluids. Alternatively, the application of an electric potential can be used to create changes in local pH near the anode reservoir cap to allow normally insoluble ions or oxidation products to become soluble.

15   This would allow the reservoir to dissolve and expose the release system to the surrounding fluids. In either case, the molecules to be delivered are released into the surrounding fluids by diffusion out of or by degradation or dissolution of the release system. The frequency of release is controlled by incorporation of a miniaturized power source and

20   microprocessor onto the microchip. Activation of any reservoir can be achieved by preprogramming the microprocessor, by remote control, or by a signal from a biosensor.

Description of the Drawings

Figure 1 depicts a typical fabrication scheme for a passive delivery

25   device.

Figure 2 depicts a typical fabrication scheme for an active delivery device.

Figure 3 depicts a typical device control circuitry flowsheet.

Figure 4 depicts a passive delivery device.

30   Figure 5 depicts an active delivery device.

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Figure 6 depicts an active device including insulator overlayers.

Figures 7a-i are schematic views of several configurations of passive delivery devices.

Figures 8a-c are schematic views of several configurations of

5   active delivery devices.

Detailed Description

Microchip devices have been provided which can accurately deliver drugs and other molecules at defined rates and times according to the needs of the patient or other experimental system. As used herein, a

10   "microchip" is a miniaturized device fabricated using methods commonly applied to the manufacture of integrated circuits such as ultraviolet (UV) photolithography, reactive ion etching, and electron beam evaporation, as described, for example, by S. Wolf and R.N. Tauber, *Silicon Processing for the VLSI Era, Volume 1 - Process Technology*, Lattice Press, Sunset

15   Beach, CA, 1986; and R.C. Jaeger, *Introduction to Microelectronic Fabrication*, Volume V in the Modular Series on Solid State Devices, Addison-Wesley, Reading, MA, 1988. The microchips provide control over the rate the molecules are released as well as the time at which release begins. The time of release can be controlled passively or

20   actively. The microchip fabrication procedure allows the manufacture of devices with primary dimensions (length of a side if square or rectangular, or diameter if circular) ranging from a few millimeters to several centimeters. A typical device thickness is 300 μm. However, the thickness of the device can vary from approximately 10 μm to several

25   millimeters. Changing the device thickness affects the maximum number of reservoirs that may be incorporated onto a microchip and the volume of each reservoir. *In vivo* applications of the device would typically require devices having a primary dimension of 2 cm or smaller. Devices for *in vivo* applications are small enough to be swallored or implanted

30   using minimally invasive procedures. Smaller *in vivo* devices (on the order of a millimeter) can be implanted using a catheter or other

injectable means. Devices for *in vitro* applications have fewer size restrictions and, if necessary, can be made much larger than the dimension ranges for *in vivo* devices.

MATERIALS FOR DEVICE FABRICATION

5   Each device consists of a substrate, reservoirs, and a release system containing, enclosing, or layered with the molecules to be delivered. Devices which control the release time of the molecules may include reservoir caps. Active devices may include control circuitry and a power source.

10   *The substrate*

The substrate contains the etched or machined reservoirs and serves as the support for the microchip. Any material which can serve as a support, is suitable for etching or machining, and is impermeable to the molecules to be delivered and to the surrounding fluids, for example,

15   water, blood, electrolytes or other solutions, may be used as a substrate. Biocompatibility of the substrate material is preferred, but not required. For *in vivo* applications, non-biocompatible materials may be encapsulated in a biocompatible material, such as poly(ethylene glycol) or polytetrafluoroethylene-like materials, before use. One example of a

20   strong, non-degradable, easily etched substrate that is impermeable to the molecules to be delivered and the surrounding fluids is silicon. In another embodiment, the substrate is made of a strong material that degrades or dissolves over a period of time into biocompatible components. This embodiment is preferred for *in vivo* applications where the device is

25   implanted and physical removal of the device at a later time is not feasible or recommended, for example, brain implants. An example of a class of strong, biocompatible materials are the poly(anhydride-*co*-imides), discussed by K.E. Uhrich *et al.*, "Synthesis and characterization of degradable poly(anhydride-*co*-imides)", *Macromolecules*, 1995, 28, 2184-

30   93.

Release system

The molecules to be delivered may be inserted into the reservoirs in their pure form, as a liquid solution or gel, or they may be encapsulated within or by a release system. As used herein, "release system" includes both the situation where the molecules are in pure form, as either a solid or liquid, or are in a matrix formed of degradable material or a material which releases incorporated molecules by diffusion out of or disintegration of the matrix. The molecules can be sometimes contained in a release system because the degradation, dissolution or diffusion properties of the release system provide a method for controlling the release rate of the molecules. The molecules can be homogeneously or heterogeneously distributed within the release system. Selection of the release system is dependent on the desired rate of release of the molecules. Both non-degradable and degradable release systems can be used for delivery of molecules. Suitable release systems include polymers and polymeric matrices, non-polymeric matrices, or inorganic and organic excipients and diluents such as, but not limited to, calcium carbonate and sugar. Release systems may be natural or synthetic, although synthetic release systems are preferred due to the better characterization of release profiles. The release system is selected based on the period over which release is desired, generally in the range of at least three to twelve months for *in vivo* applications. In contrast, release times as short as a few seconds may be desirable for some *in vitro* applications. In some cases, continuous (constant) release from a reservoir may be most useful. In other cases, a pulse (bulk) release from a reservoir may provide more effective results. Note that a single pulse from one reservoir can be transformed into pulsatile release by using multiple reservoirs. It is also possible to incorporate several layers of a release system and other materials into a single reservoir to achieve pulsatile delivery from a single reservoir. Continuous release can be achieved by incorporating a release system that degrades, dissolves, or allows diffusion of molecules through

it over an extended period of time. In addition, continuous release can be stimulated by releasing several pulses of molecules in quick succession.

The release system material can be selected so that molecules of various molecular weights are released from a reservoir by diffusion out

5   or through the material or degradation of the material. Biodegradable polymers, bioerodible hydrogels, and protein delivery systems are preferred for release of molecules by diffusion, degradation, or dissolution. In general, these materials degrade or dissolve either by enzymatic hydrolysis or exposure to water *in vivo* or *in vitro*, or by

10   surface or bulk erosion. Representative synthetic, biodegradable polymers include: poly(amides) such as poly(amino acids) and poly(peptides); poly(esters) such as poly(lactic acid), poly(glycolic acid), poly(lactic-*co*-glycolic acid), and poly(caprolactone); poly(anhydrides); poly(orthoesters); poly(carbonates); and chemical derivatives thereof

15   (substitutions, additions of chemical groups, for example, alkyl, alkylene, hydroxylations, oxidations, and other modifications routinely made by those skilled in the art), copolymers and mixtures thereof.

Representative synthetic, non-degradable polymers include: poly(ethers) such as poly(ethylene oxide), poly(ethylene glycol), and

20   poly(tetramethylene oxide); vinyl polymers - poly(acrylates) and poly(methacrylates) such as methyl, ethyl, other alkyl, hydroxyethyl methacrylate, acrylic and methacrylic acids, and others such as poly(vinyl alcohol), poly(vinyl pyrolidone), and poly(vinyl acetate); poly(urethanes); cellulose and its derivatives such as alkyl, hydroxyalkyl, ethers, esters,

25   nitrocellulose, and various cellulose acetates; poly(siloxanes); and any chemical derivatives thereof (substitutions, additions of chemical groups, for example, alkyl, alkylene, hydroxylations, oxidations, and other modifications routinely made by those skilled in the art), copolymers and mixtures thereof.

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Molecules to be released

Any natural or synthetic, organic or inorganic molecule or mixture thereof can be delivered. In one embodiment, the microchip is used to deliver drugs systemically to a patient in need thereof. In another embodiment, the construction and placement of the microchip in a patient enables the localized release of drugs that may be too potent for systemic delivery. As used herein, drugs are organic or inorganic molecules, including proteins, nucleic acids, polysaccharides and synthetic organic molecules, having a bioactive effect, for example, anaesthetics, vaccines, chemotherapeutic agents, hormones, metabolites, sugars, immunomodulators, antioxidants, ion channel regulators, and antibiotics. The drugs can be in the form of a single drug or drug mixtures and can include pharmaceutically acceptable carriers. In another embodiment, molecules are released *in vitro* in any system where the controlled release of a small (milligram to nanogram) amount of one or more molecules is required, for example, in the fields of analytic chemistry or medical diagnostics. Molecules can be effective as pH buffering agents, diagnostic agents, and reagents in complex reactions such as the polymerase chain reaction or other nucleic acid amplification procedures.

Reservoir caps

In the passive timed release drug delivery devices, the reservoir caps are formed from a material that degrades or dissolves over time, or does not degrade or dissolve but is permeable to the molecules to be delivered. These materials are preferably polymeric materials. Materials can be selected for use as reservoir caps to give a variety of degradation rates or dissolution rates or permeabilities to enable the release of molecules from different reservoirs at different times and, in some cases, different rates. To obtain different release times (amounts of release time delay), caps can be formed of different polymers, the same polymer with different degrees of crosslinking, or a UV polymerizable polymer. In the latter case, varying the exposure of this polymer to UV light results in varying degrees of crosslinking and gives the cap material different

diffusion properties or degradation or dissolution rates. Another way to obtain different release times is by using one polymer, but varying the thickness of that polymer. Thicker films of some polymers result in delayed release time. Any combination of polymer, degree of

5   crosslinking, or polymer thickness can be modified to obtain a specific release time or rate. In one embodiment, the release system containing the molecules to be delivered is covered by a degradable cap material which is nearly impermeable to the molecules. The time of release of the molecules from the reservoir will be limited by the time necessary for the

10   cap material to degrade or dissolve. In another embodiment, the cap material is non-degradable and is permeable to the molecules to be delivered. The physical properties of the material used, its degree of crosslinking, and its thickness will determine the time necessary for the molecules to diffuse through the cap material. If diffusion out of the

15   release system is limiting, the cap material delays the onset of release. If diffusion through the cap material is limiting, the cap material determines the release rate of the molecules in addition to delaying the onset of release.

     In the active timed release devices, the reservoir caps consist of a

20   thin film of conductive material that is deposited over the reservoir, patterned to a desired geometry, and serves as an anode. Cathodes are also fabricated on the device with their size and placement dependent on the device's application and method of electric potential control. The anode is defined as the electrode where oxidation occurs. Any conductive

25   material capable of dissolving into solution or forming soluble ions or oxidation compounds upon application of an electric potential can be used for the fabrication of the anodes and cathodes. In addition, materials that normally form insoluble ions or oxidation products in response to an electric potential can be used if, for example, local pH changes near the

30   anode cause these oxidation products to become soluble. Examples of suitable reservoir cap materials include metals such as copper, gold, silver, and zinc, and some polymers, as described, for example, by I.C.

Kwon *et al.*, "Electrically erodible polymer gel for controlled release of drugs", *Nature*, **1991**, 354, 291-93; and Y.H. Bae *et al.*, "Pulsatile drug release by electric stimulus", *ACS Symposium Series*, **1994**, 545, 98-110.

Device packaging, control circuitry, and power source

5   Microelectronic device packages are typically made of an insulating or dielectric material such as aluminum oxide or silicon nitride. Their purpose is to allow all components of the device to be placed in close proximity and to facilitate the interconnection of components to power sources and to each other. For *in vivo* applications of the delivery

10   device, the entire package, including all components (i.e. the device, the microprocessor, and the power source), are coated or encapsulated in a biocompatible material such as poly(ethylene glycol) or polytetrafluoroethylene-like materials. The materials requirements for *in vitro* applications may be less stringent and depend on the particular

15   situation.

The control circuitry consists of a timer, a demultiplexer, a microprocessor, and a input source, for example, a memory source, a signal receiver, or a biosensor. The timer and demultiplexer circuitry can be designed and incorporated directly onto the surface of the microchip

20   during electrode fabrication. The criteria for selection of a microprocessor are small size, low power requirement, and the ability to translate the output from memory sources, signal receivers, or biosensors into an address for the direction of power through the demultiplexer to a specific reservoir on the delivery device. Selection of a source of input to

25   the microprocessor such as memory sources, signal receivers, or biosensors depends on the delivery device's particular application and whether device operation is preprogrammed, controlled by remote means, or controlled by feedback from its environment (i.e. biofeedback).

The criteria for selection of a power source are small size,

30   sufficient power capacity, ability to be integrated into the control circuitry, the ability to be recharged, and the length of time before recharging is necessary. Several lithium-based, rechargeable

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microbatteries have been described by S.D. Jones and J.R. Akridge, "Development and performance of a rechargeable thin-film solid-state microbattery", *Journal of Power Sources*, **1995**, 54, 63-67; and J.B. Bates *et al.*, "New amorphous thin-film lithium electrolyte and

5 rechargeable microbattery", *IEEE 35th International Power Sources Symposium*, **1992**, 337-39. These batteries are typically only ten microns thick and occupy 1 cm^2 of area. One or more of these batteries can be incorporated directly onto the delivery device.

METHODS OF DEVICE FABRICATION

10 *Fabrication of the reservoirs*

Devices are manufactured using methods known to those skilled in the art, reviewed, for example, by Wolf *et al.* (1986); and Jaeger (1988); Kwon *et al.* (1991).

In a preferred method of microchip manufacture, depicted in

15 Figures 1 and 2, passive and active devices, respectively, fabrication begins by depositing and photolithographically patterning a material, typically an insulating or dielectric material, onto the substrate to serve as an etch mask during reservoir etching. Typical insulating materials for use as a mask include silicon nitride, silicon dioxide, and some polymers,

20 such as polyimide. In a preferred embodiment, a thin film (approximately 1000-3000 Å) of amorphous silicon nitride (SiN$_x$) is deposited on both sides of a silicon wafer 30/300 by Plasma Enhanced Chemical Vapor Deposition (PECVD). Alternatively, a low stress, silicon-rich nitride can be deposited in a Vertical Tube Reactor (VTR), or a stoichiometric,

25 polycrystalline nitride can be deposited by Low Pressure Chemical Vapor Deposition (LPCVD). Reservoirs are patterned into the silicon nitride film on one side of the wafer 32/320 by ultraviolet photolithography and either plasma etching or a chemical etch consisting of hot phosphoric acid. The patterned silicon nitride serves as an etch mask for the

30 chemical etching of the exposed silicon 34/340 by a concentrated potassium hydroxide solution (approximately 38.5% wt. at a temperature of 80-85°C). Alternatively, the reservoirs can be etched into the substrate

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by dry etching techniques such as reactive ion etching or ion beam
etching. These techniques are commonly used in the fabrication of
microelectronic devices, as reviewed, for example, by Wolf *et al.* (1986)
and Jaeger (1988). Use of these microfabrication techniques allows the
5   incorporation of hundreds to thousands of reservoirs on a single
microchip. In a passive device, the reservoirs may be as little as one μm
apart. In an active device, the distance between the reservoirs may be
slightly larger (approximately 10-15 μm) due to the space occupied by the
electrodes on or near each reservoir. Reservoirs can be made in nearly
10   any shape and depth, and need not pass completely through the substrate.
In a preferred embodiment, the reservoirs etched into a (100) silicon
substrate by potassium hydroxide are in the shape of a square pyramid
having side walls sloped at 54° and pass completely through the substrate
(approximately 300 μm) to the silicon nitride film on the other side of the
15   substrate, forming a SiN_4 membrane. (Here, the silicon nitride film
serves as a potassium hydroxide etch stop.) The pyramidal shape allows
easy filling of the reservoirs through the large opening of the reservoir
(approximately 500 μm by 500 μm) on the patterned side of the substrate,
release through the small opening of the reservoir (approximately 30 μm
20   by 30 μm) on the other side of the substrate, and provides a large cavity
inside the device for storing the drugs or other molecules to be delivered.

Fabrication of passive timed release reservoir caps

In the fabrication of passive timed release microchips, the
reservoir cap material is injected with a micro-syringe 36a, printed with
25   an inkjet printer cartridge, or spin coated 36b into a reservoir having the
thin film of insulating mask material still present over the small opening
of the reservoir. If injection or inkjet printing methods are used, cap
formation is complete after the material is injected or printed into the
reservoir 38a and does not require further processing. If spin coating is
30   used, the cap material is planarized by multiple spin coatings 36b. The
surface of the film is then etched by a plasma, an ion beam, or chemical
etchant until the desired cap thickness is obtained 38b. In a preferred

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embodiment, the insulating material used is silicon nitride and the cap material is printed into the reservoir with an inkget cartridge filled with a solution of the cap material.

Reservoir caps control the time at which molecules are released
5   from the reservoirs. Each reservoir cap can be of a different thickness or have different physical properties to vary the time at which each release system containing the molecules is exposed to the surrounding fluids. Injection, inkjet printing, and spin coating are the preferred methods of reservoir filling and any of these methods may be used to fill reservoirs,
10   regardless of the reservoir's shape or size. However, injection and inkjet printing are the preferred methods of filling deep (greater than 10 μm) reservoirs or reservoirs with large openings (greater than 100 μm). For example, to obtain different cap thicknesses using injection, different amounts of cap material are injected or printed directly into each
15   individual reservoir. Spin coating is the preferred method of filling shallow (less than 10 μm) reservoirs, reservoirs that do not pass completely through the substrate, or reservoirs with small (less than 100 μm) openings. Variation in cap thickness or material by spin coating can be achieved by a repeated, step-wise process of spin coating, masking
20   selected reservoirs, and etching. For example, to vary cap thickness with spin coating, the cap material is spin coated over the entire substrate. Spin coating is repeated, if necessary, until the material is nearly planarized. A mask material such as photoresist is patterned to cover the cap material in all the reservoirs except one. Plasma, ion beam, or
25   chemical etchant are used to etch the cap material in the exposed reservoir to the desired thickness. The photoresist is then removed from the substrate. The process is repeated as a new layer of photoresist is deposited and patterned to cover the cap material in all the reservoirs except one (the exposed reservoir is not the same one already etched to its
30   desired thickness). Etching of the exposed cap material in this reservoir continues until the desired cap thickness is obtained. This process of depositing and patterning a mask material such as photoresist, etching,

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and mask removal can be repeated until each reservoir has its own unique cap thickness. The techniques, UV photolithography, plasma or ion beam etching, etc., are well known to those skilled in the field of microfabrication.

5   Although injection, inkjet printing and spin coating are the preferred methods of cap fabrication, it is understood that each reservoir can be capped individually by capillary action, by pulling or pushing the material into the reservoir using a vacuum or other pressure gradient, by melting the material into the reservoir, by centrifugation and related 10   processes, by manually packing solids into the reservoir, or by any combination of these or similar reservoir filling techniques.

Once a cap fabrication method is selected, additional methods for controlling the time of release of molecules from a reservoir can be utilized. Two non-limiting examples include either UV polymerizable 15   polymers or the layering of release system and cap materials. First, if the reservoir caps are made of either an injected, inkjet printed or spin coated UV polymerizable polymer, each cap can be exposed to a different intensity of UV light to give varying degrees of crosslinking and therefore, different degradation or dissolution rates for degradable caps or 20   different permeabilities to the molecules for non-degradable caps. Second, layers of cap material, both degradable and non-degradable, can be inserted between layers of the release system containing the molecules to be delivered by injection, inkjet printing, spin coating, or selective crosslinking. These and other similar methods allow complex release 25   profiles (i.e. pulsatile delivery at irregular time intervals) to be achieved from a single reservoir.

If desired, a passive timed release device can be fabricated without reservoir caps. The rate of release of the molecules is thus solely controlled by the physical and material properties of the release system 30   containing the molecule to be delivered.

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Fabrication of active timed release reservoir caps

In a preferred embodiment, photoresist is patterned in the form of
electrodes on the surface of the substrate having the reservoirs covered by
the thin membrane of insulating or dielectric material. The photoresist is
5   developed such that the area directly over the covered opening of the
reservoir is left uncovered by photoresist and is in the shape of an anode.
A thin film of conductive material capable of dissolving into solution or
forming soluble ions or oxidation compounds upon the application of an
electric potential is deposited over the entire surface using deposition
10   techniques such as chemical vapor deposition, electron or ion beam
evaporation, sputtering, spin coating, and other techniques known in the
art. Exemplary materials include metals such as copper, gold, silver, and
zinc and some polymers, as disclosed by Kwon *et al.* (1991) and Bae *et
al.* (1994). After film deposition, the photoresist is stripped from the
15   substrate. This removes the deposited film, except in those areas not
covered by photoresist (lift-off technique). This leaves conducting
material on the surface of the substrate in the form of electrodes 360. An
alternative method involves depositing the conductive material over the
entire surface of the device, patterning photoresist on top of the
20   conductive film using UV or infrared (IR) photolithography, so that the
photoresist lies over the reservoirs in the shape of anodes, and etching the
unmasked conductive material using plasma, ion beam, or chemical
etching techniques. The photoresist is then stripped, leaving conductive
film anodes covering the reservoirs. Typical film thicknesses of the
25   conductive material may range from 0.05 to several microns. The anode
serves as the reservoir cap and the placement of the cathodes on the
device is dependent upon the device's application and method of electric
potential control.

An insulating or dielectric material such as silicon oxide (SiO_x) or
30   silicon nitride (SiN_x) is deposited over the entire surface of the device by
methods such as chemical vapor deposition (CVD), electron or ion beam
evaporation, sputtering, or spin coating. Photoresist is patterned on top

of the dielectric to protect it from etching except on the cathodes and the portions of the anodes directly over each reservoir 380. The dielectric material can be etched by plasma, ion beam, or chemical etching techniques. The purpose of this film is to protect the electrodes from

5   corrosion, degradation, or dissolution in all areas where electrode film is not necessary for release.

The electrodes are positioned in such a way that when an electric between an anode and a cathode, the unprotected (not covered by dielectric) portion of the anode reservoir cap oxidizes to form soluble

10 compounds or ions that dissolves into solution, exposing the release system containing the molecules to the surrounding fluids. The molecules are released from the reservoir at a rate dependent upon the degradation or dissolution rate of a degradable release system or the rate of diffusion of the molecules out of or through a non-degradable release system.

15 *Removal of the insulator membrane (reservoir etch stop)*

The thin membrane of insulating or dielectric material covering the reservoir used as a mask and an etch stop during reservoir fabrication must be removed from the active timed release device before filling reservoir 400 and from the passive timed release device (if the reservoir

20 extends completely through the substrate) after filling reservoir 44. The film may be removed in two ways. First, the film can be removed by an ion beam or reactive ion plasma. In a preferred embodiment, the silicon nitride film used as the insulating material can be removed by a reactive ion plasma composed of oxygen and fluorine containing gases such as

25 CHF_3 or CF_4. Second, the film can be removed by chemical etching. For example, buffered hydrofluoric acid (BHF or BOE) can be used to etch silicon dioxide and hot phosphoric acid can be used to etch silicon nitride.

Reservoir filling

The release system containing the molecules for delivery is inserted into the large opening of the reservoir by injection, inkjet printing or spin coating 40a/40b/400. Each reservoir can contain a different molecule and dosage. Similarly, the release kinetics of the molecule in each reservoir can be varied by the choice of the release system and cap materials. In addition, the mixing or layering of release system and cap materials in each reservoir can be used to tailor the release kinetics to the needs of a particular application.

The distribution over the microchip of reservoirs filled with the release system containing the molecules to be delivered can vary depending on the medical needs of the patient or other requirements of the system. For applications in drug delivery, for example, the drugs in each of the rows can differ from each other. One row may contain a hormone and another row may contain a metabolite. Also, the release system can differ within each row to release a drug at a high rate from one reservoir and a slow rate from another reservoir. The dosages can also vary within each row. For those devices having deep (greater than 10 μm) reservoirs or reservoirs with large (greater than 100 μm) openings, differences in reservoir loading can be achieved by injection or inkjet printing of different amounts of material directly into each reservoir. Variation between reservoirs is achieved in devices having shallow (less than 10 μm) reservoirs, reservoirs that do not pass completely through the substrate, or reservoirs with small (less than 100 μm) openings by a repeated, step-wise process of masking selected reservoirs, spin coating, and etching, as described above regarding the fabrication by spin coating of passive timed release reservoir caps. Preferably, the release system and molecules to be delivered are mixed before application to the reservoirs. Although injection, inkjet printing and spin coating are the preferred methods of filling reservoirs, it is understood that each reservoir can be filled individually by capillary action, by pulling or pushing the material into the reservoir using a vacuum or other pressure gradient, by

melting the material into the reservoir, by centrifugation and related processes, by manually packing solids into the reservoir, or by any combination of these or similar reservoir filling techniques.

Device packaging, control circuitry, and power source

5   The openings through which the reservoirs of passive and active devices are filled are sealed by wafer bonding or with a waterproof epoxy or other appropriate material impervious to the surrounding fluids 44/440. For *in vitro* applications, the entire unit, except for the face of the device containing the reservoirs and electrodes, is encased in a material

10   appropriate for the system. For *in vivo* applications, the unit would be encapsulated in a biocompatible material such as poly(ethylene glycol) or polytetrafluoroethylene.

The mechanism for release of molecules by the active timed release device does not depend on multiple parts fitted or glued together

15   which must retract or dislodge. Control of the time of release of each reservoir can be achieved by a preprogrammed microprocessor, by remote control, by a signal from a biosensor, or by any combination of these methods, as shown schematically in Figure 3. First, a microprocessor is used in conjunction with a source of memory such as programmable read

20   only memory (PROM), a timer, a demultiplexer, and a power source such as a microbattery, such as is described, for example, by Jones *et al.* (1995) and Bates *et al.* (1992). The release pattern is written directly into the PROM by the user. The PROM sends these instructions to the microprocessor. When the time for release has been reached as indicated

25   by the timer, the microprocessor sends a signal corresponding to the address (location) of a particular reservoir to the demultiplexer. The demultiplexer sends an input, such as an electric potential, to the reservoir addressed by the microprocessor. A microbattery provides the power to operate the PROM, timer, and microprocessor, and provides the electric

30   potential input that is directed to a particular reservoir by the demultiplexer. The manufacture, size, and location of each of these components is dependent upon the requirements of a particular

-20-

application. In a preferred embodiment, the memory, timer, microprocessor, and demultiplexer circuitry is integrated directly onto the surface of the chip. The microbattery is attached to the other side of the chip and is connected to the device circuitry by vias or thin wires.

5   However, in some cases, it is possible to use separate, prefabricated, component chips for memory, timing, processing, and demultiplexing. These are attached to the backside of the miniaturized delivery device with the battery. The size and type of prefabricated chips used depends on the overall dimensions of the delivery device and the number of

10   reservoirs. Second, activation of a particular reservoir by the application of an electric potential can be controlled externally by remote control. Much of the circuitry used for remote control is the same as that used in the preprogrammed method. The main difference is that the PROM is replaced by a signal receiver. A signal such as radio waves, low power

15   laser, or ultrasound is sent to the receiver by an external source, for example, computers or ultrasound generators. The signal is sent to the microprocessor where it is translated into a reservoir address. Power is then directed through the demultiplexer to the reservoir having the appropriate address. Third, a biosensor is integrated into the microchip to

20   detect molecules in the surrounding fluids. When the concentration of the molecules reaches a certain level, the sensor sends a signal to the microprocessor to activate one or more reservoirs. The microprocessor directs power through the demultiplexer to the particular reservoir(s).

       Electric Potential Control Methods

25   The reservoir caps of an active device are anodes that oxidize to form soluble compounds and ions when a potential is applied between the anode and a cathode. For a given electrode material and electrolyte, there exists a range of electric potentials over which these oxidation reactions are thermodynamically and kinetically favorable. In order to reproducibly

30   oxidize and open the device's reservoir caps, the anode potential must be maintained in this potential range.

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There exist two primary control methods for maintaining an electrode within a specific potential range. The first method is called potentiostatic control. As the name indicates, the potential is kept constant during reservoir activation. Control of the potential is typically

5   accomplished by incorporating a third electrode into the system that has a known, constant potential, called a reference electrode. The reference electrode can take the form of an external probe whose tip is placed within one to three mm of the anode surface. The potential of the anode is measured and controlled with respect to the known potential of a

10   reference electrode such as a saturated calomel electrode (SCE). In a preferred embodiment of potentiostatic control, a thin film reference electrode and potential feedback controller circuitry could be fabricated directly onto the surface of the microchip. For example, a microfabricated Ag/AgCl reference electrode integrated with a microchip

15   device would enable the device to maintain the anode potential of an activated reservoic within the oxidation regime until the reservoir was completely opened. The second method is called galvanostatic control. As the name indicates, the current is kept constant during reservoir activation. One drawback to this method of control is that there is more

20   than one stable potential for a given current density. However, if the current density versus potential behavior is well characterized for the microchip device in a particular electrolyte system, the current density that will maintain the anode in teh oxidation regime will be known. In this case, the galvanostatic method of potential control would be

25   preferable to the potentiostatic control, because galvanostatic control does not require a reference electrode.

MICROCHIP APPLICATIONS

Passive and active microchip devices have numerous *in vitro* and *in vivo* applications. The microchip can be used *in vitro* to deliver small,

30   controlled amounts of chemical reagents or other molecules to solutions or reaction mixtures at precisely controlled times and rates. Analytical chemistry and medical diagnostics are examples of fields where the

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microchip delivery device can be used. The microchip can be used *in vivo* as a drug delivery device. The microchips can be implanted into a patient, either by surgical techniques or by injection, or can be swallowed. The microchips provide delivery of drugs to animals or

5 persons who are unable to remember or be ambulatory enough to take medication. The microchips further provide delivery of many different drugs at varying rates and at varying times of delivery.

The present invention will be further understood by reference to the following non-limiting examples.

10 *Example 1: Microchip with passive timed drug release.*

A passive timed release device, microchip 10 is shown in Figure 4. Microchip 10 is formed from substrate 14. Reservoirs 16 are etched into substrate 14. Positioned in reservoirs 16 is a release system containing molecules 18 for delivery. The reservoirs are capped with

15 reservoir caps 12. The release system and the molecules for delivery 18 can vary between rows 20a, 20b, 20c, and within reservoirs of each row.

Microchip 10 can be inserted into solution for *in vitro* applications or be implanted in a selected part of the body or swallowed for *in vivo* applications and left to operate without requiring further attention. When

20 exposed to the surrounding fluids, reservoir caps 12 will degrade, dissolve or become permeable to the release system containing molecules for delivery 18.

Figures 7a-i depict several additional possible configurations for passive delivery devices.

25 *Example 2: Microchip with active controlled time release.*

A drug delivery device that provides active timed release is shown as microchip 100 in Figure 5. Microchip 100 is similar to microchip 10 except that microchip 100 contains electrodes that provide for active timed release. Microchip 100 is formed from substrate 160, release system

30 containing molecules 180 for delivery, anode reservoir caps 120, and cathodes 140. Preferably, microchip 100 further includes an input source, a microprocessor, a timer, a demultiplexer, and a power source

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(not shown). The power source provides energy to drive the reaction between selected anodes and cathodes. Upon application of a small potential between an anode and cathode, electrons pass from the anode to the cathode through the external circuit causing the anode material to

5   oxidize and form soluble compounds or ions that dissolve into the surrounding fluids, exposing the release system containing the molecules for delivery 180 to the surrounding fluids. The microprocessor directs power to specific electrode pairs through a demultiplexer as directed by a PROM, remote control, or biosensor.

10   Figure 6 is a schematic of a second embodiment of a microchip 200 from from substrate 260 actively releasing drug 280 from the device upon application of an electric potential between an anode and cathode, which, unlike the device in Figure 5, includes an insulator overlayer.

         Figures 8a-c depicts three additional possible configurations for

15   active delivery devices.

We claim:

1. A microchip device for the release of molecules comprising
a substrate, and
a plurality of reservoirs in the substrate, wherein the
reservoirs controllably release molecules incorporated therein.

2. The device of claim 1 wherein the reservoirs comprise
different types of molecules, different amounts of molecules, or
combinations thereof.

3. The device of claim 1 wherein release of the molecules is
controlled by a release system incorporating the molecules in the
reservoir.

4. The device of claim 3 further comprising degradable
reservoir caps positioned on the reservoirs over the release system,
wherein the degradation rate of the cap determines the time at which the
molecules are released from the reservoir.

5. The device of claim 4 wherein the reservoir caps have
different thicknesses.

6. The device of claim 4 wherein the release system in a
reservoir degrades or dissolves to release the molecules after the reservoir
cap is degraded or dissolved.

7. The device of claim 4 wherein pulsatile release is obtained
from a single reservoir by layering different release system and reservoir
cap materials in the reservoir.

8. The device of claim 4 wherein the release system is non-
degradable, and diffusion of the molecules out of the release system
provides a pulsed release of the molecules after the degradation of the
reservoir cap.

9. The device of claim 3 comprising non-degradable reservoir
caps positioned on the reservoirs over the release system, wherein the rate
of diffusion of the molecules through the cap determines the time at which
the molecules are released from the reservoirs.

-25-

10.   The device of claim 4 further comprising cathodes, a microprocessor, a timer, a demultiplexer, and a power source, wherein the reservoir caps are anodes and are each surrounded by one of the cathodes, wherein upon application of an electric potential between each cathode and anode, the reservoir cap oxidizes, dissolves in solution, and exposes the underlying release system to the surrounding fluids.

11.   The device of claim 10 wherein the microprocessor function is directed by a source of memory preprogrammed to activate the electrodes of individual reservoirs at specific times.

12.   The device of claim 10 wherein the microprocessor function is directed by remote control to activate the electrodes of each reservoir.

13.   The device of claim 10 further comprising a biosensor, wherein the microprocessor function is directed by the biosensor to activate the electrodes of each reservoir.

14.   The device of claim 2 wherein the release system comprises drug molecules in an excipient or diluent.

15.   The device of claim 14 wherein the release system in each reservoir is formed of the molecules to be released, wherein the dissolution rate of the molecules determines the rate of release of the molecules.

16.   A method of fabricating a device for the release of molecules comprising:

    providing a substrate;

    depositing and patterning an insulating material on the substrate for use as an etch mask;

    etching a plurality of reservoirs in the substrate;

    filling the reservoirs with release system and cap materials; and

    etching release system and cap materials.

17.   The method of claim 16 further comprising removing a thin film of insulating material over the reservoirs.

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18.   The method of claim 16 further comprising filling each reservoir with different types and amounts of cap materials and release systems containing molecules to be delivered.

19.   The method of claim 16 wherein the reservoirs are filled by injection, inkjet printing or spin coating.

20.   The method of claim 19 wherein the reservoirs are filled by inkjet printing.

21.   The method of claim 17 further comprising depositing a thin film of conductive material over the thin film of insulating material over each reservoir.

22.   The method of claim 21 further comprising patterning the conductive film into electrodes so that an anode covers each reservoir opening and a cathode surrounds each anode.

23.   The method of claim 22 further comprising depositing a material over each electrode, except the anode directly over the reservoir and the cathode surrounding the exposed portion of the anode.

24.   A method for the delivery of molecules comprising
            providing at a site where the molecules are to be delivered
        a microchip device for the release of molecules comprising a
        substrate, and a plurality of reservoirs in the substrate, wherein the
        reservoirs controllably release molecules incorporated therein.

25.   The method of claim 24 wherein the molecules are drugs, comprising administering, implanting or injecting the microchip into a patient.

26.   The method of claim 25 wherein the molecules are a drug selected from the group consisting of nucleic acids, proteins, amino acids, polysaccharides, and organic or synthetic molecules.

27.   The method of claim 26 wherein the drugs are in combination with a pharmaceutically acceptable carrier.

28.   The method of claim 24 wherein the molecules are diagnostic or chemical reagents.

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29.   The method of claim 24 wherein the molecules are released in a pulsatile or continuous manner.

30.   The method of claim 24 wherein the release system is formed by the molecules to be released.

31.   The method of claim 24 wherein degradable reservoir caps are positioned on the reservoirs over the release system, wherein the degradation, dissolution or diffusion rate of the cap determines the time at which the molecules are released from the reservoir.

32.   The method of claim 24 wherein the device further comprises cathodes, a microprocessor, a timer, a demultiplexer, and a power source, wherein the reservoir caps are anodes and are each surrounded by one of the cathodes, wherein the method further comprises applying an electric potential between each cathode and anode, to oxidize the reservoir cap and expose the underlying release system to the surrounding fluids.

33.   The method of claim 32 wherein the microprocessor function is directed by a source of memory preprogrammed to activate the electrodes of individual reservoirs at specific times, wherein the method further comprises programming the memory.

34.   The method of claim 32 wherein the microprocessor function is directed by remote control to activate the electrodes of each reservoir.

35.   The method of claim 32 wherein the device further comprises a biosensor, wherein the microprocessor function is directed by the biosensor to activate the electrodes of each reservoir.

Reservoir Cap Material

Insulator/Etch Mask Material

Release System Containing the
Drug or other Molecule
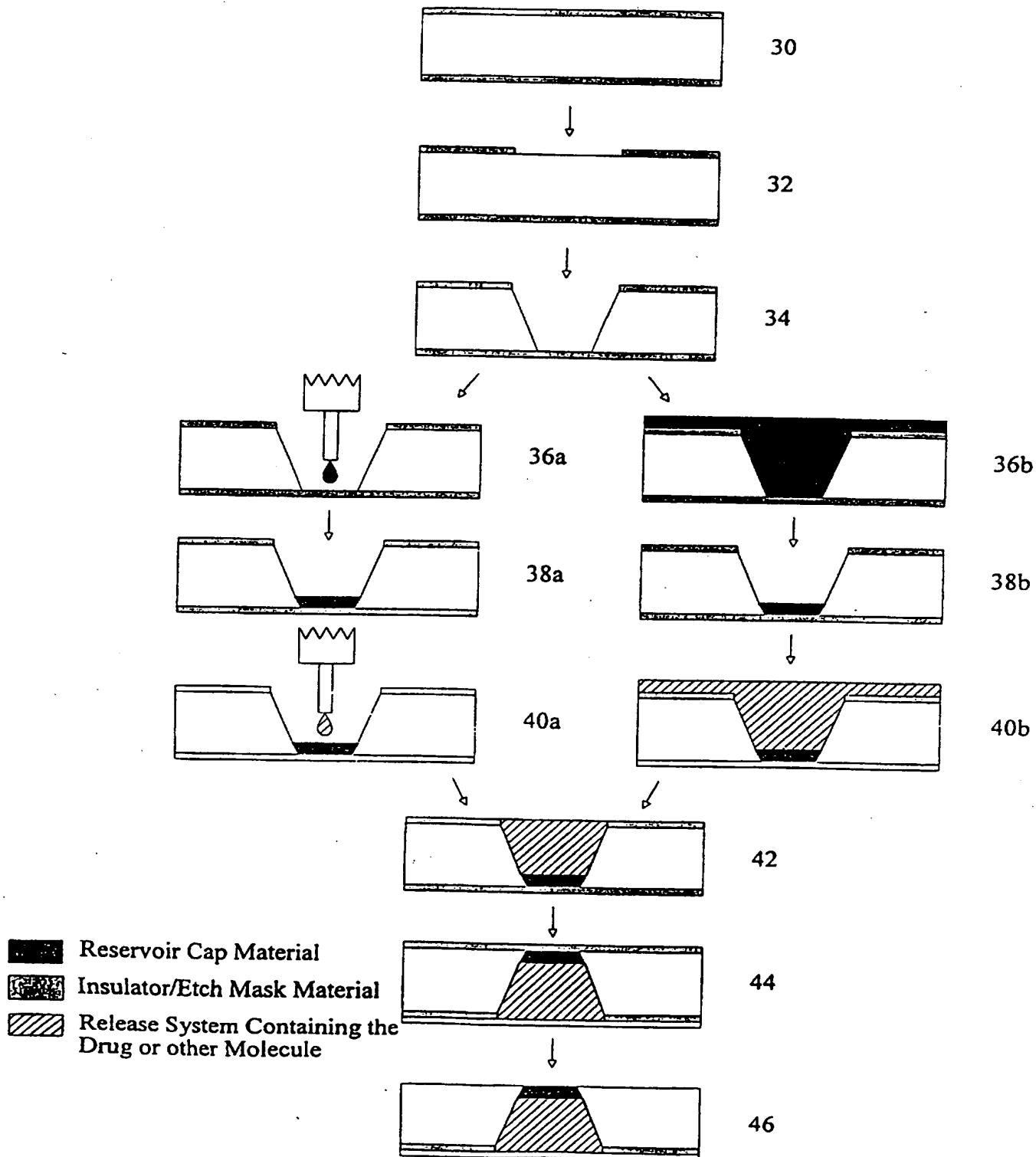
Figure 1. Fabrication of a Passive Device

300

320

340

360

380

400

420

440

■■■■ Anode and Cathode Material
▨ Insulator/Etch Mask Material
▦ Insulator Overlayer
▨ Release System Containing the
Drug or other Molecule
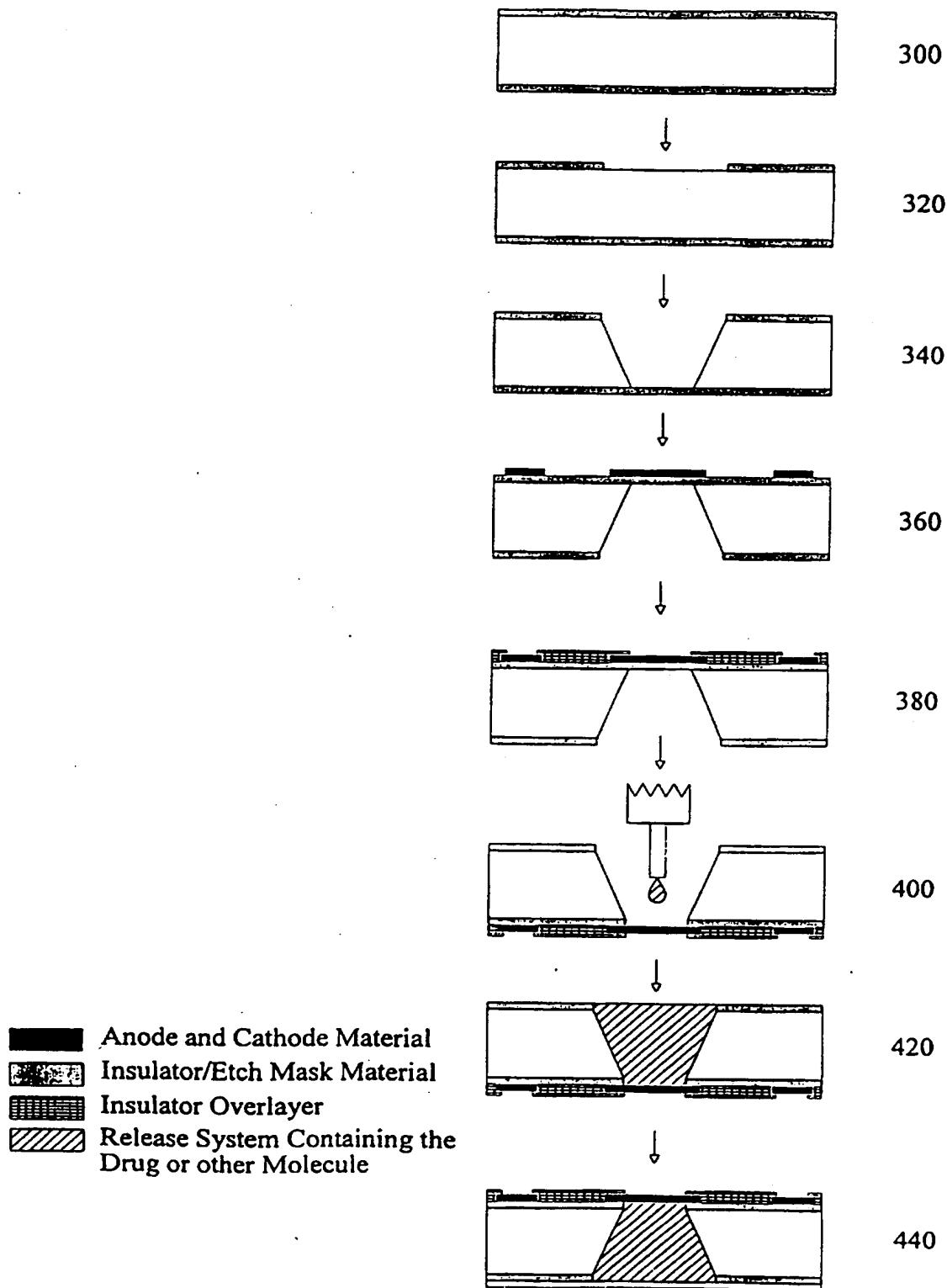
Figure 2. Fabrication of an Active Device
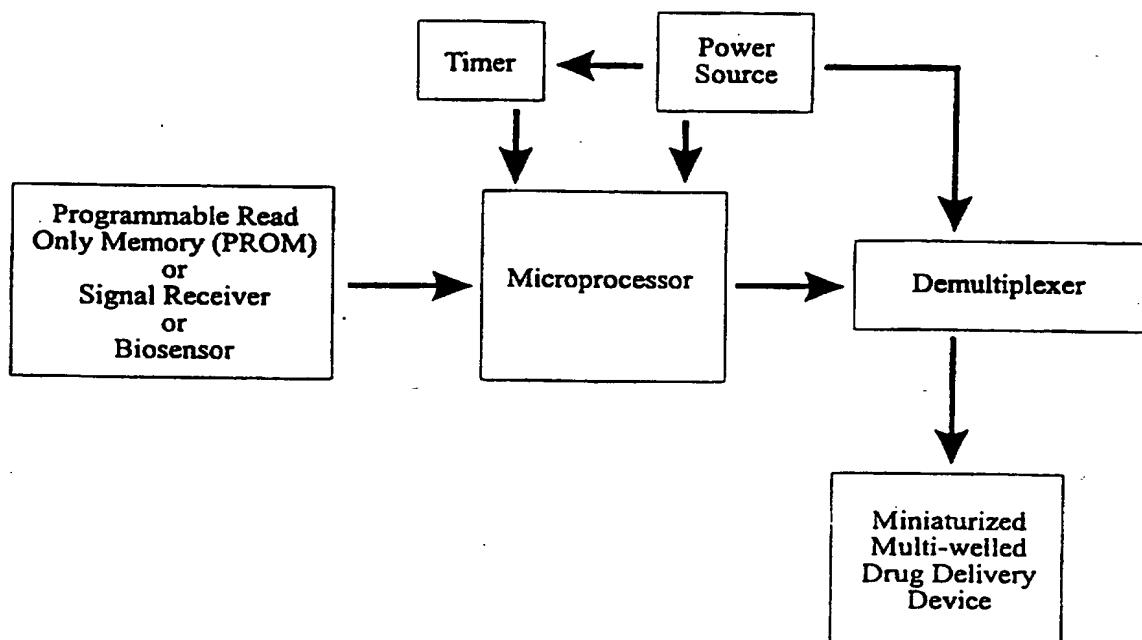
Figure 3. Flowsheet of Device Control Circuitry

Microchip 10

↓

20c

20b

20a

12

14

16

18
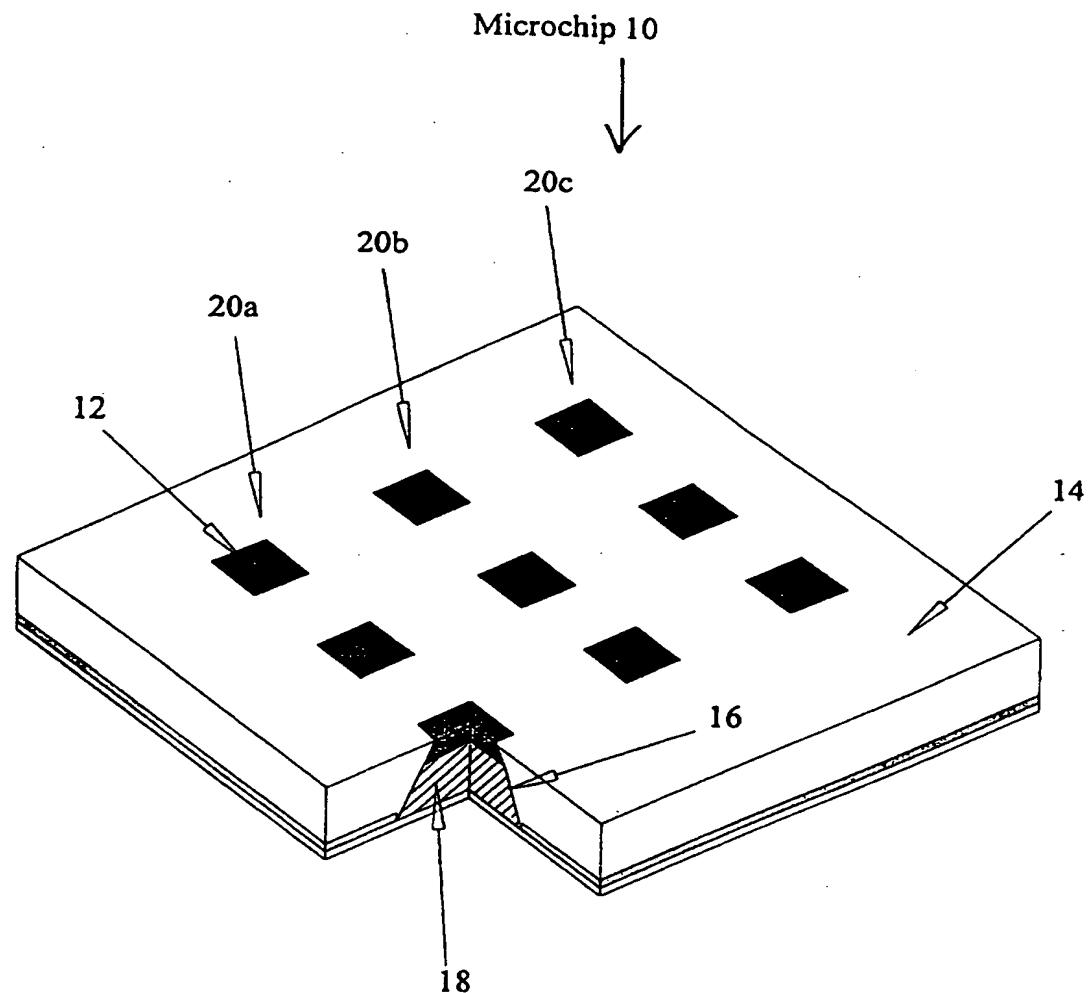
▨▨▨	Release System Containing the Drug or other Molecule
■■■	Reservoir Cap Material
▨▨▨	Insulator/Etch Mask Material

Figure 4. Schematic of a Passive Device
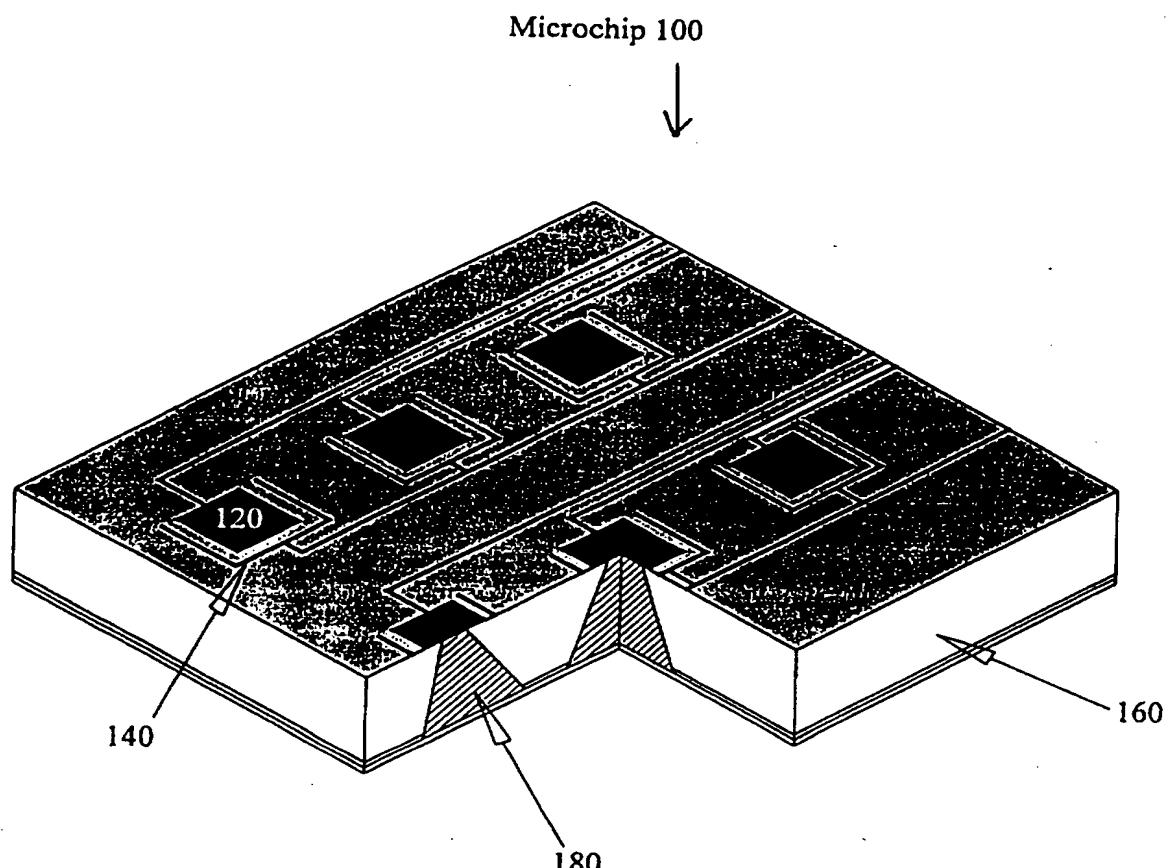
Microchip 100

↓

Release System Containing the Drug or other Molecule

Anode and Cathode Material

Insulator/Etch Mask Material

Figure 5. Schematic of an Active Device
(not including insulator overlayer)
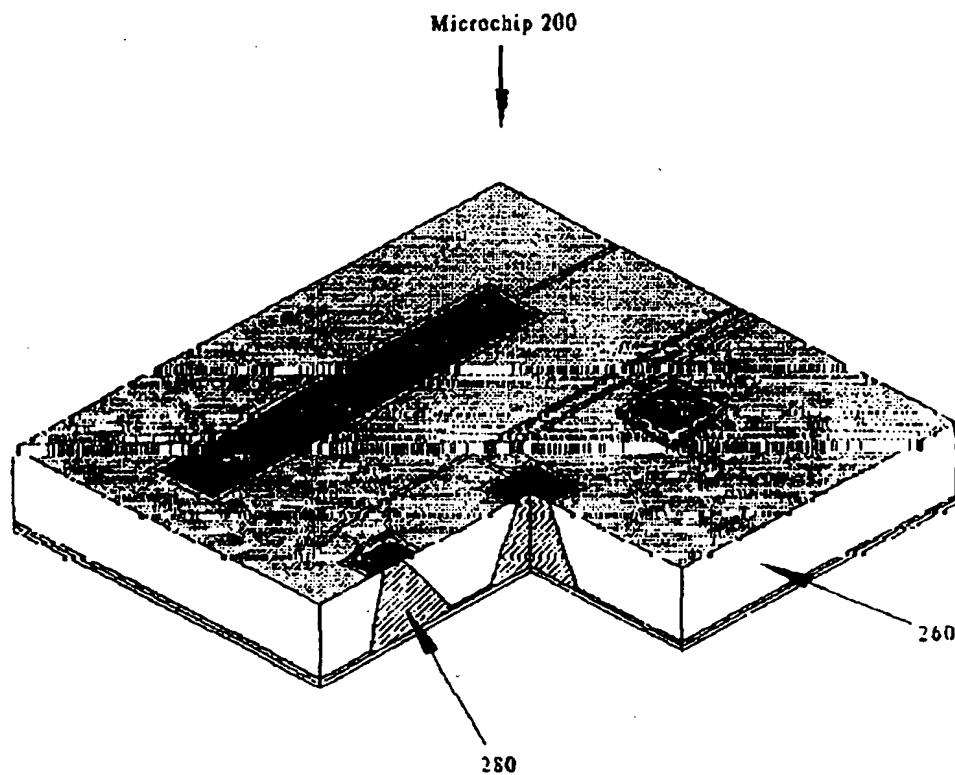
Microchip 200

260

280

[/////] Release System Containing the Drug or other Molecule

[■■■■■] Anode and Cathode Material

[▓▓▓▓▓] Insulator Overlayer & Etch Mask Material

Figure 6. Schematic of an Active Device

(including insulator overlayer)
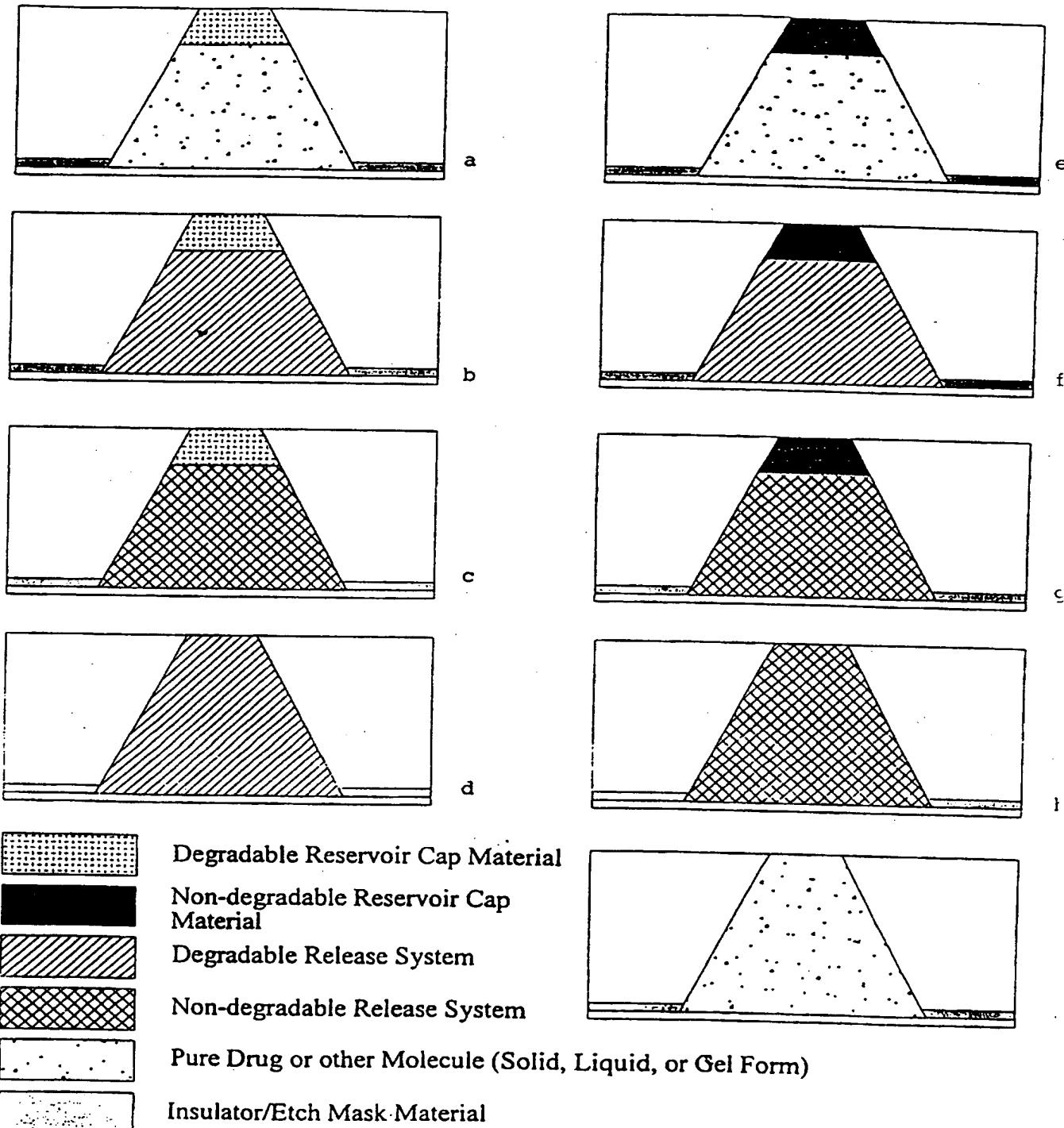
Figure 7. Several Possible Configrations for Passive
Delivery Devices
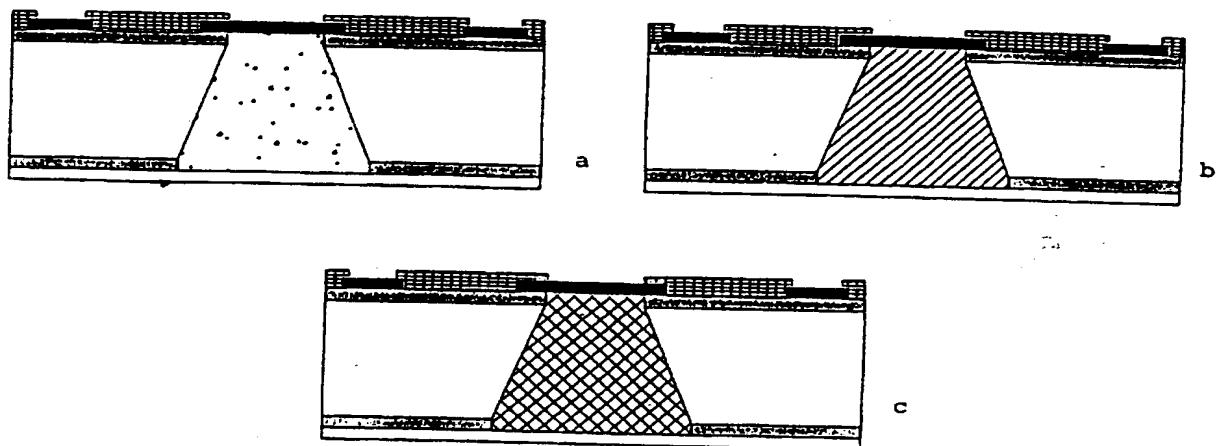
	Insulator/Etch Mask Material
	Anode and Cathode Material
	Insulator Overlayer
	Degradable Release System
	Non-degradable Release System
	Pure Drug or other Molecule (Solid, Liquid, or Gel Form)

Figure 8. Several Possible Configrations for Active
Delivery Devices